

MS AMENDMENT  
PATENT  
0171-1022P

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant:	Takeshi KINSHO et al.	Conf.:	6775
Appl. No.:	10/671,732	Group:	1752
Filed:	September 29, 2003	Examiner:	Sin J. LEE
For:	POLYMERIZABLE SILICON-CONTAINING COMPOUND, MANUFACTURING METHOD, POLYMER, RESIST COMPOSITION AND PATTERNING PROCESS		

LARGE ENTITY TRANSMITTAL FORM

**MS AMENDMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

April 20, 2005

Sir:

Transmitted herewith is an amendment in the above-identified application.

- ☐ The enclosed document is being transmitted via the Certificate of Mailing provisions of 37 C.F.R. § 1.8.
- ☐ The enclosed document is being transmitted via facsimile.

The fee has been calculated as shown below:

	CLAIMS REMAINING AFTER AMENDMENT					HIGHEST NUMBER PREVIOUSLY PAID FOR	PRESENT EXTRA	RATE	ADDITIONAL FEE
TOTAL	17	-	20	=	0		\$50	\$0.00	
INDEPENDENT	4	-	3	=	1		\$200	\$200.00	
<input type="checkbox"/> FIRST PRESENTATION OF A MULTIPLE DEPENDENT CLAIM							\$360	\$0.00	
							TOTAL	\$200.00	

- ☐ Petition for ( ) month(s) extension of time pursuant to 37 C.F.R. §§ 1.17 and 1.136(a). \$0.00 for the extension of time.
- ☐ No fee is required.
- ☒ Check(s) in the amount of \$200.00 is(are) enclosed.
- ☐ Please charge Deposit Account No. 02-2448 in the amount of \$0.00. This form is submitted in triplicate.

If necessary, the Commissioner is hereby authorized in this, concurrent, and future replies, to charge payment or credit any overpayment to Deposit Account No. 02-2448 for any additional fees required under 37 C.F.R. § 1.16 or under 37 C.F.R. § 1.17; particularly, extension of time fees.

Respectfully submitted,

BIRCH, STEWART, KOLASCH & BIRCH, LLP

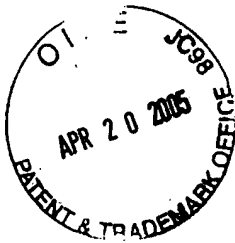
By 

Andrew D. Meikle, #32,868

ADM/bsh  
0171-1022P

P.O. Box 747  
Falls Church, VA 22040-0747  
(703) 205-8000

Attachment(s)



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Appl. No.: 10/671,732 Group: 1752  
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For: POLYMERIZABLE SILICON-CONTAINING COMPOUND,  
MANUFACTURING METHOD, POLYMER, RESIST  
COMPOSITION AND PATTERNING PROCESS

REPLY UNDER 37 C.F.R. § 1.111

**MS AMENDMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

April 20, 2005

Sir:

In reply to the Office Action dated January 25, 2005, the following amendments and remarks are respectfully submitted in connection with the above-identified application.

This reply includes amendments to the claims and remarks.